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Atty. Docket No.: 3600-328-01	Application No.:	10/042,549
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Applicant:	Christopher A. MICHALUK	
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Filing Date: January 9, 2002	Group Art Unit:	Not Yet Assigned
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U.S. PATENT DOCUMENTS

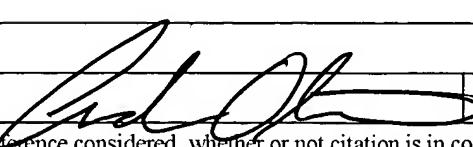
Examiner Initial*		Document Number	Date	Name	Class	Sub Class	Filing Date If Appropriate
Aro	1	2,950,185	08/23/60	E.G. Hellier et al.	75	0.5	
Aro	2	3,767,456	10/23/73	Glaski	117	71 M	
Aro	3	3,829,310	08/13/74	T.X. Mahy	75	0.5 BB	
Aro	4	4,149,876	04/17/79	Rerat	75	0.5 BB	
Aro	5	4,684,399	08/04/87	Bergman et al.	75	0.5	
Aro	6	5,234,491	08/10/93	Chang	75	622	
Aro	7	5,242,481	09/07/93	Kumar	75	364	
Aro	8	6,193,821	02/27/01	Zhang	148	668	
Aro	9	2001/0001401	05/24/01	Segal	148	670	

FOREIGN PATENT DOCUMENTS

		Document Number	Date	Country	Class	Sub Class	Translation Yes or No
Aro	10	WO 00/31310	06/02/00	WIPO	—	—	Yes

OTHER DOCUMENTS (Including Author, Title, Date, Pertinent Pages, Etc.)

Aro	Kirk-Othmer, Encyclopedia of Chemical Technology, 3rd Edition, Vol. 22, pp. 541-564.
Aro	S.I. Wright, G.T. Gray, and A.D. Rollett, <i>Textural and Microstructural Gradient Effects on the Mechanical Behavior of a Tantalum Plate</i> , Metallurgical and Materials Transactions A, 25A, pp. 1025-1031, 1994.
Aro	C.A. Michaluk, R.O. Burt, and D.P. Lewis, <i>Tantalum 101: Economics and Technology of Ta Materials</i> , Semiconductor International, Vol. 23, No. 8, pp. 271-278, 2000.
Aro	C.A. Michaluk, <i>Correlating Discrete Orientation and Grain Size to the Sputter Deposition Properties of Tantalum</i> , Journal of Electronic Materials, Vol. 31, No. 1, pp. 2-9, 2002.

Examiner		Date Considered	4/22/03
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*Examiner: Initial if reference considered, whether or not citation is in conformance with MPEP 609; draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.

Form PTO 1449	Patent and Trademark Office - U.S. Department of Commerce
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Page 1 of 1

TRADEMARK FORM PTO-1449 (REV 7-80)	Atty. Docket No. CPM00029CIP(3600-328-01)	Application No. 10/042,549
INFORMATION DISCLOSURE STATEMENT		APPLICANT: Christopher A. MICHALUK Filing Date: January 9, 2002 Group Art Unit: 1742

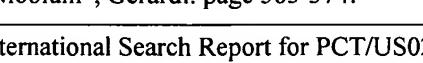
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		DOCUMENT NUMBER	DATE	COUNTRY	CLASS	SUB-CLASS	TRANSLATION YES	NO
Aro		WO 01/96620	12/20/01	WIPO	C22B			
Aro		WO 99/61670	12/2/99	WIPO	C22B	34/24		
Aro		WO 99/66100	12/23/99	WIPO	C23C	14/34		

OTHER DOCUMENTS (Including Author, Title, Date, Pertinent Pages, Etc.)

<i>Arc</i>	G. I. Friedman, "Grain Size Refinement in a Tantalum Ingot", Metallurgical Transactions., vol. 2, January 1971(1971-01), pages 337-341, XP002227180 METALLURGICAL SOCIETY OF AIME. NEW YORK., US. Page 337, column 1, line 1-page 340, column 2, line 28; table 4.
<i>Arc</i>	S. R. Lampman et al., "Metals Handbook, Vol 2", 1990 ASM INTERNATIONAL, Ohio, US XP002227181, "Niobium", Gerardi. page 565-574.
<i>Arc</i>	International Search Report for PCT/US02/23640
EXAMINER 	DATE CONSIDERED 4/22/03

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